Following the successful previous International Symposia on SiAlONs and Non-oxides in 2001, 2007 and 2010, this meeting is intended to provide a broader forum to present the most recent developments in research and applications of SiAlON and non-oxide ceramics. The symposium will also have a focus on new processing techniques and novel applications including environmental and energy issues of non-oxide ceramics.

**Proposed Topics**
- New SiAlON, nitride and carbide phases
- Polymer derived non-oxide ceramics
- Powder processing
- Microstructural design and control
- Nano- and micro-composites
- Porous non-oxide ceramics
- Functional SiAlONs and non-oxide ceramics
- Applications for SiAlONs and non-oxides
- Environmentally-related non-oxide ceramics

**Language**
English is the official language. All printed materials, presentation and discussion will be in English. There will no simultaneous translations.

**Conference Venue and Accommodation**
Nagahama Royal Hotel
8 Oshima, Oshima Town, Nagahama City, Shiga 526-0066, Japan
Tel: +81-749-642000, Fax: +81-749-642005

**Submission of Abstracts**
Individuals interested in presenting papers are requested to submit an abstract of about 200 words to the following address before 15th February, 2014.

Prof. Junichi Tatami
Yokohama National University, Japan
e-mail : issnox4@ml.ynu.ac.jp

The abstract should be presented in the following format in Times New Roman 12pt font.

Line 1: Title of the presentation
Line 2: Names of authors (mark the presenting author with an asterisk *)
Line 3: The affiliation, city, post code and country
Line 4: E-mail address of the presenting author
Line 5: Abstract content

A template file of the abstract can be downloaded from the ISSNOX4 website.
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Program (tentative)

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<tr>
<td>25th May</td>
<td>16:00 -</td>
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<td>Welcome reception</td>
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Registration

Registration fees are:
- Participants: 50,000 yen
- Student: 15,000 yen

Registration method of ISSNOX4 will be announced on the website in the course of time.

Further Information

For further information please contact

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Fax: +81-45-3393959
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Symposium web site:
http://ceramics.ynu.ac.jp/issnox4/index.html

SECOND CIRCULAR

4th INTERNATIONAL SYMPOSIUM ON SiAlONs AND NON-OXIDES

May 25th – 28th, 2014
Nagahama Royal Hotel, Shiga, Japan

Co-sponsored by JSPS 124th Committee on Advanced Ceramics
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